

10/019244

Page 1 of 3

JC13 Rec'd PCT/PTO 21 DEC 2001

FORM PTO-1449 (Modified) LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	ATTY. DOCKET NO. 1446NP	SERIAL NO. To Be Assigned
	APPLICANT: Prasad Narhar GADGIL	
	FILING DATE: Herewith	GROUP: To Be Assigned

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

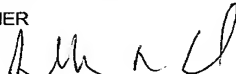
EXAMINER INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
AK	4 9 9 3 3 5 7	02/19/91	Scholz	118	715	
AK	5 2 4 2 5 3 0	09/07/93	Batey et al.	156	613	
AK	5 2 5 6 2 0 5	10/26/93	Schmitt, III et al.	118	723	
AK	5 2 8 1 2 7 4	01/25/94	Yoder	118	697	
AK	5 3 1 6 7 9 3	05/31/94	Wallace et al.	427	248.1	
AK	5 3 4 2 6 6 0	08/30/94	Cann et al.	427	577	

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation
AK	0 0 1 5 3 9 0	17.09.80	EPO	—	—	

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

AK	<input checked="" type="checkbox"/>	Hurle, D.T.J., "Thin Films and Epitaxy," Handbook of Crystal Growth, Vol. 3, 1994, pp. 606-663.
AK	<input checked="" type="checkbox"/>	Ju, H. et al., "GaAs Atomic Layer Epitaxy in a Rotating Disc Reactor," SPIE, Vol. 1676, 1992, pp. 20-25.

EXAMINER 	DATE CONSIDERED 11/25/03
---	-----------------------------

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

10/019244

Page 2 of 3
JC13 Rec'd PCT/PTO 21 DEC 2001

FORM PTO-1449 (Modified)	ATTY. DOCKET NO.	SERIAL NO.
	1446NP	To Be Assigned
	APPLICANT:	
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	Prasad Narhar GADGIL	
(Use several sheets if necessary)	FILING DATE:	GROUP:
	Herewith	To Be Assigned

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
AK	5 8 1 0 9 4 2	09/22/98	Narayanswami et al.	134	7	
AK	5 8 7 9 4 5 9	03/09/99	Gadgil et al.	118	715	

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

AK	✓	McIntosh, F.G. et al., "Silicon Monolayer Growth Using Dichlorosilane and Hydrogen in a Near Atmospheric Pressure Chemical Vapor Deposition Reactor," Thin Solid Films 225, 1993, pp. 183-186.
AK	✓	Reid, K.G. et al. "The Role of Gas Phase Decomposition in the Ale Growth of III-V Compounds," North Carolina State University, Electrical & Computer Engineering Dept., Raleigh, NC., pp. 133-138.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

JC13 Rec'd PCT/PTO Page 3 of 3
21 DEC 2001

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.